

Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of Claims:

1. (Original) A shadow mask material characterized by containing 0.0001 to 0.1% by weight of Ti and not more than 0.003% by weight of C in its composition, the balance thereof being Fe and unavoidable impurities.

2. (Original) A shadow mask material characterized by containing not more than 0.003% by weight of C, not more than 0.03% by weight of Si, 0.1 to 0.5% by weight of Mn, not more than 0.02% by weight of P, not more than 0.02% by weight of S, 0.01 to 0.07% by weight of Al, not more than 0.0040% by weight of N, not more than 0.01% by weight of B, not more than 0.1% by weight of Nb and 0.0001 to 0.1% by weight of Ti in its composition, the balance thereof being Fe and unavoidable impurities.

3. (Original) A process for producing a shadow mask material characterized by hot rolling a steel slab containing not more than 0.004% by weight of C and 0.0001 to

0.1% by weight of Ti in its composition, the balance thereof being Fe and unavoidable impurities, pickling a hot rolled product, cold rolling a pickled product, subjecting a cold rolled product to continuous or box annealing to reduce its carbon content to not more than 0.003% by weight and subjecting it to secondary cold rolling at a draft of 20 to 92%.

4. (Original) A process for producing a shadow mask material characterized by hot rolling a steel slab containing not more than 0.004% by weight of C, not more than 0.03% by weight of Si, 0.1 to 0.5% by weight of Mn, not more than 0.02% by weight of P, not more than 0.02% by weight of S, 0.01 to 0.07% by weight of Al, not more than 0.0040% by weight of N, not more than 0.01% by weight of B, less than 0.01% by weight of Nb and 0.0001 to 0.1% by weight of Ti in its composition, the balance thereof being Fe and unavoidable impurities, pickling a hot rolled product, cold rolling a pickled product, subjecting a cold rolled product to continuous or box annealing to reduce its carbon content to not more than 0.003% by weight and subjecting it to secondary cold rolling at a draft of 20 to 92%.

5. (Original) A process for producing a shadow mask material characterized by hot rolling a steel slab containing not more than 0.004% by weight of C, not more than 0.03% by weight of Si, 0.1 to 0.5% by weight of Mn, not more than 0.02% by weight of P, not more than 0.02% by weight of S, 0.01 to 0.07% by weight of Al, not more than 0.0040% by weight of N, not more than 0.01% by weight of B, 0.01 to 0.1% by weight of Nb and 0.0001 to 0.1% by weight of Ti in its composition, the balance thereof being Fe and unavoidable impurities, pickling a hot rolled product, cold rolling a pickled product, subjecting a cold rolled product to continuous or box annealing to reduce its carbon content to not more than 0.003% by weight and subjecting it to secondary cold rolling at a draft of 70% or less.

6. (Currently Amended) A shadow mask formed from a shadow mask material as set forth in claim ~~1 or 2~~.

7. (Currently Amended) A shadow mask manufactured by employing a process for producing a shadow mask material as set forth in ~~any of claims 3 to 5~~ claim 3.

8. (Currently Amended) A picture tube having incorporated therein a shadow mask as set forth in claim 6—~~or~~ 7.

9. (New) A shadow mask formed from a shadow mask material as set forth in claim 2.

10. (New) A shadow mask manufactured by employing a process for producing a shadow mask material as set forth in claim 4.

11. (New) A shadow mask manufactured by employing a process for producing a shadow mask material as set forth in claim 5.

12. (New) A picture tube having incorporated therein a shadow mask as set forth in claim 7.

13. (New) A picture tube having incorporated therein a shadow mask as set forth in claim 9.

14. (New) A picture tube having incorporated therein a shadow mask as set forth in claim 10.

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15. (New) A picture tube having incorporated therein a shadow mask as set forth in claim 11.